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APPLICATION NO. 09/886984 F 430 SUBCLASS ART UNIT 1756

Ji-Suk Hong Hee-Bom Kim Sang-Sool Koo

Method for forming a phase-shifting mask for semiconductor device manufacture

ORIGINAL CROSS REFERENCE(S)

CLASS SUBCLASS CLASS SUBCLASS (ONE SUBCLASS PER BLOCK)

INTERNATIONAL CLASSIFICATION

COntinued on Issue Slip Inside File Jacket

TERMINAL	DRAWINGS			CLAIMS ALLOWED	
- DISCLAIMER	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
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subsequent to (date) has been disclaimed.	(Assistant	Examiner)	(Date)		
The term of this patent shall not extend beyond the expiration date					
of U.S Patent. No.			ISSUE FEE		
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